Reactions of Alkyl Alkylidene Complexes with Silanes. Synthesis and Characterization of Novel Tantalum 1,1-Metallasilacyclobutadiene and **Disilyl-Substituted Alkylidene Complexes**

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We have been investigating cyclopentadienyl (Cp)-free silyl alkylidene complexes of tantalum as models for possible reactive intermediates in the reactions of alkyl alkylidene complexes (RCH₂)₃Ta=CHR with SiH₄.^{1,2} Recently, we reported the synthesis and characterization of thermally unstable silvl alkylidene complexes (Me₃ECH₂)₂Ta(=CHEMe₃)SiPh₂Bu^t (E = C, 1; Si, 2), which react with PMe₃ to form bis(phosphine) bis(alkylidene) complexes (Me₃ECH₂)Ta(PMe₃)₂[=CHEMe₃]₂² (E = C, 3; Si, 4; 3 has been previously prepared by Schrockand co-workers³). In order to further study the reaction of silane with alkyl alkylidene complexes, we investigated the reactions of tantalum alkylidene complexes containing phosphine supporting ligands with silanes $PhR'SiH_2$ (R' = Ph, Me), in the hope that phosphine might help stabilize the resulting products.

When a solution of PhR'SiH₂ (1 equiv) was added to a solution of 4, we were surprised to find immediate H₂ evolution from the solution⁴ and formation of a novel metallasilacyclobutadiene complex (5, Scheme 1).⁵ Similarly, addition of a solution of PhR'SiH₂ to a solution of (Me₃SiCH₂)₃Ta- (PMe_3) =CHSiMe₃ (6)⁶ resulted in a nearly quantitative conversion (by NMR) of 6 to (Me₃SiCH₂)₃Ta[=C(SiMe₃)SiPhR'H] (7),⁵ again with evolution of H_2 . The reaction of the silane with 4 and 6 occurred *exclusively* with the =CHSiMe₃ ligands, and the resulting products 5 and 7 were inert toward further reaction with excess silane. In contrast, Berry and co-workers have observed that $Cp_2Ta(=CH_2)CH_3$ reacts with tBu_2SiH_2 to give Cp₂Ta(H)=CHSiHBu^t₂ through a mechanism involving oxidative addition of the silane to a d² center, followed by CH₄ elimination and alkylidene transfer and insertion steps.^{7a} Bercaw and co-workers have reported that the formation of d⁰ Cp*₂- $Ta(H)(CH_3)SiH_3$ (Cp* = pentamethylcyclopentadienyl) from the reaction of d^0 Cp*₂Ta(H)=CH₂ with SiH₄ is through the oxidative addition of SiH₄ to d² Cp*₂Ta-CH₃, which is in equilibrium with $Cp*_2Ta(H)=CH_2$.^{7b} It is interesting to point out that no reaction was observed between 4 and ^tBu₂SiH₂ in benzene- d_6 , even at 65 °C.⁸

Spectroscopic properties of 5 and 7 are consistent with the structure assignments.⁵ The ¹³C NMR alkylidene resonances of 5a,b and 7a,b range from 238.2 to 255.4 ppm and appear as



singlets in the gated-decoupled ¹³C spectra. The molecular structures of 5a,b have been determined by X-ray crystallography and are found to be similar. The structure of 5a is shown in Figure 1.9 Complex 5a exhibits distorted trigonal bipyramidal geometry around the tantalum center, with the PMe₃ ligands occupying axial positions. The Ta=C bond distances of 1.947(12) and 1.962(12) Å are consistent with those observed for other alkylidene complexes of tantalum (1.998(8) and 1.95(2) Å in 4,² 1.932(7) and 1.955(7) Å in Ta(=CHBu^t)₂-(mesityl)(PMe₃)₂,¹⁰ and 1.932(9) Å in [Ta(=CHBu^t)(CH₂Bu^t)- $(PMe_3)_2]_2(\mu - N_2)^{11}$). The metallasilacyclobutadiene ring in 5a is planar (average deviation from least-squares plane = 0.007Å), which brings the silicon atom in close proximity to the tantalum center (Ta-Si distance of 2.607(3) Å); however, the fact that the metal center is formally d⁰ makes any metal-silicon bonding interaction unlikely.¹² The silicon atom of the metallasilacyclobutadiene ring in 5a exhibits distorted tetrahedral geometry, with bond angles ranging from 96.7(5)° to 115.9- $(6)^{\circ}$. The structure of **5a** is novel, and to our knowledge represents the first example of a 1,1-metallasilacyclobutadiene complex. A number of metallasilacyclobutane complexes have been synthesized and structurally characterized by Marks, Girolami, Wilkinson, Petersen, and others,¹³⁻¹⁶ and a large number of conjugated metallacyclobutadiene complexes are known;¹⁷ however, to our knowledge, complexes **5a**,**b** represent the first cyclobutadiene complexes in which both double bonds are localized exclusively on the metal atom.¹⁸

When the reaction of 6 with excess deuterated silane PhMeSiD₂ (2-5 equiv) was monitored by NMR, the predominant product was identified as (Me₃SiCH₂)₃Ta=[C(SiPhMeD)-SiMe₃] (7a-d₁),⁵ along with a trace amount of 7a. PhMeSiHD and PhMeSi H_2 were also observed in the reaction mixture. The possibility of H incorporation into PhMeSiD₂ occurring by exchange with the Me₃SiCH₂- ligands of **6** was investigated by

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⁽⁵⁾ See the Supporting Information for experimental and spectroscopic details.

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⁽⁸⁾ After a benzene-d₆ solution of **4** and excess ^tBu₂SiH₂ was heated for 24 h at 65 °C, a 5% thermal decomposition of 4 to (Me₃SiCH₂)₄Ta₂(µ-CSiMe₃)₂¹⁹ had occurred; however, no reaction with 'Bu₂SiH₂ was observed.

⁽⁹⁾ Crystal data for **5a**: monoclinic, $P2_1/n$ (No. 14), a = 10.647(3) Å, b = 17.757(6) Å, c = 18.686(5) Å, $\beta = 96.91(3)^\circ$, V = 3507(2) Å³, Z =

^{4,} $R(R_wF^2) = 5.04$ (12.40)% with 4617 unique reflections with $F > 2.0\sigma$ -(F), GOF = 1.03, number of parameters refined = 289.

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Figure 1. ORTEP of 5a, showing 50% thermal ellipsoids. Selected bond distances (Å) and angles (deg): Ta-C(1) 1.947(12), Ta-C(2) 1.962(12), Ta-C(3) 2.285(11), Ta-P(1) 2.605(3), Ta-P(2) 2.665(3), C(1)-Si(4) 1.901(11), C(2)-Si(4) 1.900(11), C(1)-Si(1) 1.832(12), C(2)-Si(2) 1.819(11), P(1)-Ta-P(2) 161.97(10), P(1)-Ta-C(3) 80.7-(3), P(2)-Ta-C(3) 85.6(3), C(1)-Ta-C(2) 93.1(4), C(1)-Ta-C(3) 134.4(4), C(2)-Ta-C(3) 132.5(4), C(1)-Si(4)-C(2) 96.7(5), Ta-C(1)-Si(4) 85.3(5), Ta-C(2)-Si(4) 84.9(5).

Scheme 2



monitoring a solution containing PhMeSiD₂ and (Me₃SiCH₂)₄- $Ta_2(\mu$ -CSiMe₃)₂,¹⁹ which we had found to be inert toward reaction with PhMeSiH₂. No such H/D exchange was observed by ¹H NMR over 2.5 h at 50 °C, ruling out exchange with residual protons in the solvent and suggesting that exchange with -CH₂SiMe₃ ligands would be unlikely. In addition, analysis of the gaseous products from the reaction with PhMeSiD₂ by mass spectrometry showed the predominant product to be D_2 , with some HD also present.5 These observations lead us to propose a possible mechanism for the formation of 7 (Scheme 2). The silane first reacts by addition across the Ta=C bond to form a hydride (deuteride) intermediate 8, which then reacts with a second equivalent of silane, producing H_2 (D₂) and a silvl intermediate 9. Complex 9 then undergoes α -hydrogen abstraction by the -SiPhR'H ligand to yield 7, reforming the silane in the process. With PhR'SiD₂, this final step would yield PhR'SiHD, which could further react to form PhR'SiH₂, consistent with the results obtained from the reaction with PhMeSiD₂.



Workup of the reaction mixture to produce 7 yields a red oil of reasonably pure (>95% by ¹H NMR) 7. However, all attempts to isolate analytically pure samples of this compound were unsuccessful, as 7 was found to be thermally unstable. When monitored by NMR in benzene- d_6 , 7 slowly decomposed through SiMe₄ elimination; however, a solution of 7 in benzene could be frozen and stored at -20 °C for several weeks without significant decomposition. When the reaction to form 7 is monitored by NMR, a partial conversion of 7 to 5, along with formation of SiMe₄, is observed after several days; 5 is not observed during the formation of 7. A possible mechanism for this conversion is shown in Scheme 3. Reactions similar to those shown in Scheme 3 may be involved in the conversion of 4 to 5: attack at one of the alkylidene ligands to produce H_2 and 10, followed by intramolecular attack of the alkylidene -SiPhR'H group on the second alkylidene as proposed above to give 5, with a small excess of silane acting as a catalyst.

The preferential reaction of the alkylidene ligands, rather than the alkyl ligands, of **4** and **6** with PhR'SiH₂ was unexpected. In order to probe whether such a preference is general, the reaction of the neopentyl analog **3** with PhMeSiH₂ was investigated. Surprisingly, no H₂ was observed; rather, a considerable amount of CMe₄ formed, along with a mixture of unidentified products.²⁰ It therefore appears that the silicon atoms in the -CH₂SiMe₃ and ==CHSiMe₃ ligands of **4** may exert an important influence over the course of the reactions of silanes with alkyl alkylidene complexes.²¹ Kinetic studies are currently underway to further probe the possible mechanistic pathways of these reactions.

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Supporting Information Available: Experimental and spectroscopic data for **5** and **7**; crystal structure of **5b** along with crystal-lographic and structural data for **5a,b** (23 pages). See any current masthead page for ordering and Internet access instructions.

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